

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: SEOK-YOON YANG, ET AL. )  
 ) Group Art Unit:  
Serial No.: 10/675,455 ) 1752  
 )  
Filed: September 30, 2003 ) Examiner:  
 ) Walke, Amanda C.  
For: PHOTSENSITIVE RESIN COMPOSITION )  
 CONTROLLING SOLUBILITY AND PATTERN )  
 FORMATION METHOD OF DOUBLE-LAYER )  
 STRUCTURE USING THE SAME )

**RESPONSE**

**VIA EFS**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir,

This Response is being filed in response to the Office Action dated September 24, 2007. A petition for a 2 month extension of time, from December 24, 2007 to February 24, 2008, accompanies this Response.